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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of: **Miwa KOZAWA et al.**

Group Art Unit: 1752

Serial Number: 10/629,806

Examiner: **Sin J. Lee**

Filed: **July 30, 2003**

Confirmation No.: 9494

For: **RESIST PATTERN THICKENING MATERIAL, PROCESS FOR  
FORMING RESIST PATTERN, AND PROCESS FOR  
MANUFACTURING SEMICONDUCTOR DEVICE**

Attorney Docket Number: 030923

Customer Number: 38834

**PETITION FOR EXTENSION OF TIME**

Commissioner for Patents  
P. O. Box 1450  
Alexandria, VA 22313-1450

September 29, 2005

Sir:

Applicants petition the Commissioner for Patents to extend the time for response to the Office Action dated April 29, 2005 for 2 months from July 29, 2005 to September 29, 2005.

Attached please find a check in the amount of \$450.00 to cover the cost of the extension.

If any additional fees are due in connection with this paper, please charge our Deposit Account No. 50-2866.

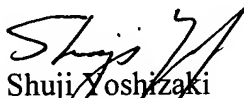
Respectfully submitted,

**WESTERMAN, HATTORI, DANIELS & ADRIAN, LLP**

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